IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):

Hamada et al.

Filed:

Concurrently Herewith

Title:

COMPOSITION FOR FORMING POROUS FILM AND METHOD FOR

FORMING THE SAME, POROUS FILM AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM, AND SEMICONDUCTOR

DEVICE

Docket No.:

035576/275601

Customer No.: 00826

March 9, 2004

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT 37 CFR § 1.115

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks begin on page 7 of this paper.